



IME-03-005

March 5, 2004

To: Commissioner for Patents  
P.O.Box 1450  
Alexandria, VA 22313-1450

Fr: George O. Saile, Reg. No. 19,572  
28 Davis Avenue  
Poughkeepsie, N.Y. 12603

Subject: | Serial No. 10/748,736 12/30/03 |  
Wong Ee Hua et al.  
| WAFER LEVEL SUPER STRETCH SOLDER |  
| \_\_\_\_\_ |

#### INFORMATION DISCLOSURE STATEMENT

Enclosed is Form PTO-1449, Information Disclosure Citation  
In An Application.

The following Patents and/or Publications are submitted to  
comply with the duty of disclosure under CFR 1.97-1.99 and  
37 CFR 1.56.

#### CERTIFICATE OF MAILING

I hereby certify that this correspondence is being  
deposited with the United States Postal Service as first class  
mail in an envelope addressed to: Commissioner for Patents,  
P.O. Box 1450, Alexandria, VA 22313-1450, on March 16, 2004.

Stephen B. Ackerman, Reg.# 37761

Signature/Date

Stephen B. Ackerman 3/16/04

U.S. Patent 5,251,806 to Agarwala et al., "Method of Forming Dual Height Solder Interconnections," discloses an interconnection and a method for making the same.

U.S. Patent 5,441,195 to Tustaniwskyj et al., "Method of Stretching Solder Joints," discusses a method of stretching solder joints between the input/output pads of an electrical component and corresponding input/output pads on a substrate.

U.S. Patent 5,964,396 to Brofman et al., "Enhanced Ceramic Ball Grid Array Using In-Situ Solder Stretch with Clip," discloses a device for stretching solder interconnection joints between two substrates of an electronic module.

U.S. Patent 5,975,409 to Brofman et al., "Ceramic Ball Grid Array Using In-Situ Solder Stretch," discloses a method and apparatus for forming an elongated solder joint between two soldered substrates of an electronic module by applying a controlled separating force between the two soldered substrates during and/or after heating of the module.

U.S. Patent 6,442,831 to Khandros et al., "Method for Shaping Spring Elements," discusses free-standing bond wires used as core elements for composite interconnection element.

U.S. Patent 5,790,377 to Schreiber et al., "Integral Copper Column with Solder Bump Flip Chip," discloses an integral copper column with a solder bump flip chip.

Larry Gilg, Die Products Consortium, Austin, TX-EP&P, 7/1/02, "Wafer-Level vs. Singulated Die Burn-In and Test," discusses IC manufacturers that supply die products developing several powerful tools to provide the reliability demanded by today's high performance ICs.

Beth Keser et al., "Encapsulated Double-Bump WL-CSP: Design and Reliability," Proc. 51st Electronic Component Tech. Conf. 2001, pp. 35-39, discusses a new type of wafer level package designed and fabricated by using an encapsulation material which is applied directly to a bumped wafer.

J. Simon, "Development and Board Level Reliability of a Wafer-level CSP," Proc. 41st IEMT/IMC 2000, pp. 22-27, discusses the requirements and limitations for waferlevel CSP manufacturing.

In the publication, S.I. Denda, et al., "Wafer Level Packaging Technology in Japan," Proc. 4th IEMT/IMC, 2000, pp. 4-9, (Fig. 2), an overview of WLP technology in Japan is made, and their categorization and possible technical problems are discussed.

Advanced IC Packaging Markets and Trends, pp. 4-49 to 4-51, Electronic Trend Publication, 6th Edition, 2002, provides innovative and integrated flip chip solutions to companies that manufacture semiconductors.

Bakir, et al., "Sea of Leads Ultra High-Density Compliant Wafer-Level Packaging Technology," Proc. 52nd Elec. Component Tech. Conf., 2002, pp. 1087-1094, discusses Sea of Leads (SoL), a novel ultra high-density compliant wafer-level packaging technology.

P. Garrou, et al., "Cyclotene BCB Resin for Bumping and Wafer Level Chip Scale Packaging (WL-CSP), Proc. 3rd IEMT/IMC, pp. 206-211, 1999, discusses wafer level CSP (WL-CSP) appearing to be a strong candidate for low cost CSP technolog of the future.

Sincerely,

A handwritten signature in black ink, appearing to read 'Stephen B. Ackerman', with a stylized flourish at the end.

Stephen B. Ackerman,  
Reg. No. 37761

Form PTO-1449

INFORMATION DISCLOSURE CITATION  
IN AN APPLICATION

(Use several sheets if necessary)

Docket Number (Optional)

IME-03-005

Application Number

10/748,736

Applicant

Wang Ec Hua et al.

Filing Date

12/30/03

Group Art Unit

## U. S. PATENT DOCUMENTS

| EXAMINER<br>INITIAL | DOCUMENT NUMBER | DATE     | TITLE               | CLASS | SUBCLASS | PUBLICATION<br>DATE<br>IF APPROPRIATE |
|---------------------|-----------------|----------|---------------------|-------|----------|---------------------------------------|
|                     | 5251806         | 10/12/93 | Agarwala et al.     | 228   | 180.22   | 4/16/92                               |
|                     | 5441195         | 8/15/95  | Tustaniwskyj et al. | 228   | 180.22   | 1/13/94                               |
|                     | 5964396         | 10/12/99 | Brofman et al.      | 228   | 180.22   | 8/12/97                               |
|                     | 5975409         | 11/2/99  | Brofman et al.      | 228   | 180.22   | 8/12/97                               |
|                     | 6442831         | 9/3/02   | Khandros et al.     | 29    | 843      | 1/24/97                               |
|                     | 5790377         | 8/4/98   | Schreiber et al.    | 361   | 704      | 9/12/96                               |
|                     |                 |          |                     |       |          |                                       |
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## FOREIGN PATENT DOCUMENTS

|  | DOCUMENT NUMBER | DATE | COUNTRY | CLASS | SUBCLASS | Translation |    |
|--|-----------------|------|---------|-------|----------|-------------|----|
|  |                 |      |         |       |          | YES         | NO |
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|  |                 |      |         |       |          |             |    |

## OTHER DOCUMENTS (Including Author, Title, Date, Portion(s) Pages, Etc.)

|   |   |
|---|---|
| - | Larry Gilg, Die Products Consortium, Austin, TX - EP4P, 7/1/02, "Wafer-Level vs. Singulated Die Burn-In and Test"                           |
| - | Beth Koser, et al., "Encapsulated Double-Bump WL-CSP: Design and Reliability", Proc. 51st Electronic Component Tech. Conf. 2001, pp. 35-39. |
| - | J. Simon, "Development and Board Level Reliability of a Wafer-level CSP", Proc. 41st IEMT/Imc 2000, pp. 22-27.                              |

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.

Form PTO-1449

## INFORMATION DISCLOSURE CITATION IN AN APPLICATION

(Use several sheets if necessary)

Doc No (Number) (Copy)

IME-03-005

Agitation Number

10 | 748,736

LogCont

Wong Ee Hua et al.

Filing Date

12/30/03

Group 1st Unit

## U. S. PATENT DOCUMENTS

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## FOREIGN PATENT DOCUMENTS

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## OTHER DOCUMENTS (Including Author, Title, Date, Portion or Pages, Etc.)

- S.I. Denda, et al., "Water Level Packaging Technology in Japan", Proc 4th IEMT/Imc, 2000, pp. 4-9, (Fig. 2).
- Advanced IC packaging markets and trends, pp. 4-49 to 4-51, Electronic Trend Publication, 6th Edition, 2002.
- Bakir, et al., "Sea of Leads Ultra High-Density Compliant Wafer-Level Packaging Technology", Proc. 52nd Elec. Component Tech. Conf.

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2002, pp. 1087-1094.

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|---|---|---------------------------------------|
| Form PTO-1449<br><br>INFORMATION DISCLOSURE CITATION<br>IN AN APPLICATION.<br><br>(Use several sheets if necessary) | Doctor (Number) (Optional)<br><b>IME-03-005</b> | Applicant Number<br><b>10/748,736</b> |
|   | Applicant<br><b>Wong Ee Hua et al.</b>          |                                       |
|   | Filing Date<br><b>12/30/03</b>                  | Group Art Unit                        |

## U. S. PATENT DOCUMENTS

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## FOREIGN PATENT DOCUMENTS

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## OTHER DOCUMENTS (Including Author, Title, Date, Portmox Pages, Etc.)

|   |   |
|---|---|
| - | P. Garrou, et al., "Cyclotene BCB Resin for Bumping and Water Level Chip Scale Packaging (WL-CSP), Proc. 3RD IEMT/IMC, pp. 206-211, 1999. |
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